

Solvay Chemicals Sifren® 46 Hexafluoro-1,3-butadiene

Category: Fluid

Material Notes:

Sifren® 46 (C4F6 or Hexafluorobutadiene) C4F6 has a GWP=0 and it is the most advanced etching gas for critical applications. Its low C/F ratio and its insaturations allow achieving the highest aspect ratios in etching. Uses: Sifren® 46 is suggested for the use in plasma, ion beam or sputter etching in semiconductor devices manufacturing. Information provided by Solvay

Order this product through the following link:

http://www.lookpolymers.com/polymer_Solvay-Chemicals-Sifren-46-Hexafluoro-13-butadiene.php

Physical Properties	Metric	English	Comments
Molecular Weight	162.03 g/mol	162.03 g/mol	

Thermal Properties	Metric	English	Comments
Melting Point	-130 °C	-202 °F	
Boiling Point	5.50 °C	41.9 °F	

Descriptive Properties	Value	Comments
Appearance	Gas	
Color	Colorless	

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